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- (71) Applicant: NANTERO, INC. [US/US]; 25-D Olympia Avenue, Woburn, MA 01801 (US).
- (72) Inventors: WARD, Jonathan, W.; 824 Arboretum Wav. Burlington, MA 01803 (US). RUECKES, Thomas; 82 Myrtle Street #2, Boston, MA 02114 (US). SEGAL, Brent, M.; 8 Prospect Avenue #1, Woburn, MA 01801 (US).
- (74) Agents: DICHIARA, Peter, M. et al.; Hale and Dorr LLP. 60 State Street, Boston, MA 02109 (US).

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(54) Title: CARBON NANOTUBE FILMS, LAYERS, FABRICS, RIBBONS, ELEMENTS AND ARTICLES

(57) Abstract: Carbon Nanotube Films, Layers, Fabrics, Ribbons, Elements and Carbon Nanotube Films, Layers, Fabrics, Ribbons, Elements and Carbon Nanotubes are applied to a surface of the substrate to create a non-woven nanotubes. Portions of the non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes a substrate is provided. Preformed nanotubes are applied to a surface of the substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes a substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes a substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes a substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes are pipiled to a surface of the substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes are pipiled to a surface of the substrate to create a non-woven fabric are selectively removed according to a defined pattern to create the article. To carbon nanotubes are pipiled to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric are selectively removed according to a surface of the substrate to create a non-woven fabric and selectively removed according to a surface of the substrate to create a non-woven desirable for various electrical systems such as memory circuits and conductive traces and pads.